

Diary of 1997/8 Events

We are keen to publicise your 1997 or 1998 meeting, workshop, exhibition or course. If you want to use *III-Vs Review* to help you with your Call for Papers please fax details to: +44 (0) 1865 843971, or email: d.finch@elsevier.co.uk

EGW-2

The Second European GaN Workshop will take place near Cannes, France on 11-13 June. Attendance will be limited to 150.
Contact: Prof. Jean-Pierre Faurie, CRHEA-CNRS, Sophia Antipolis, rue Bernard Gregory, 06560 Valbonne, France.
Tel/fax: +33 (0)4 93 95 42 20/41 42. E-mail: jpf@crhea1.unice.fr
URL: <http://crhea.unice.fr/EGW-2/Index.htm>

ICAM 97 & E-MRS 97

The International Conference on Advanced Materials and The European Materials Research Society Spring Meeting will be held jointly in Strasbourg, France, on 16-20 June 1997.
Contact: P. Siffert, E-MRS, BP 20, 67037 Strasbourg Cedex 2, France. Tel/fax: +33 (0)3 8810 6543/ 6293; E-mail: emrs@frcp-n11.in2p3.fr

ICFSI-6

The sixth International Conference on the Formation of Semiconductor Interfaces will be held in Cardiff, Wales, UK, on 23-27 June 1997.
Contact: Glenda Bland, Tel/fax: +44 (0)1222 700053/700665. E-mail: 100416.1402@compuserve.com URL: <http://www.astro.cf.ac.uk/icfsi>

1997 Electronic Materials Conference

The 39th Electronic Materials Conference will be held at the Colorado State University at Fort Collins, Colorado, USA, on 25-27 June 1997.
Contact: TMS, 420 Commonwealth Drive, Warrendale, PA 15086, USA. Tel/fax: +1 412 776-9000/-3770; e-mail: csc@tms.org

7th Si-MBE

The Seventh International Symposium on Silicon Molecular Beam Epitaxy will be held in Banff, Alberta, Canada on 13-17 July 1997.
Contact: Pierre Lamoureux, National Research Council Canada, Building M-19, Montreal Road, Ottawa, ON, Canada K1A 0R6. Tel/fax: +1 613 993-9431/-7250; E-mail: mbe97@nrc.ca; URL: <http://www.nrc.ca/confserv/mbe97/welcome.html>

II-VI 97

The II-VI Semiconductors International Conference of 1997 will take place in Grenoble, France, on 25-29 August 1997.
Contact: Dr Le Si Dang, II-VI Conference Secretariat, Laboratoire de Spectrométrie Physique, Université Joseph Fourier, Grenoble, BP 87, 38402 Saint-martin d'Herès Cedex, France. Tel/fax: +33 (0)476 514 732/544. E-mail: lesidang@spectro.ujf-grenoble.fr

ujf-grenoble.fr; URL: http://spectro.ujf-grenoble.fr/~icc_2_6

ICSCIII-N '97

The International Conference on SiC and III-Nitrides will take place in Stockholm, Sweden on 31 August-5 September 1997.
Contact: Prof. B. Mournar, Conference Chairman, Linköping University, S-58183, Sweden. Tel/fax: +46 13 281797/142337. E-mail: bom@ifm.liu.se

GaAs '97

The fifth European Gallium Arsenide Applications Symposium will be held on 3-5 September in Bologna, Italy.
Contact: Prof. Vito A. Monaco, Conference Chairman, DEIS - University of Bologna, Viale Risorgimento 2, 40136 Bologna, Italy. Tel/fax: +39 (0)51 644-3030/3073. E-mail: vamonaco@deis.unibo.it

ISCS XXIV

The 24th International Conference on Compound Semiconductors will be held at the Hotel Coronado, San Diego, CA, USA, on 7-11 September 1997.
Abstract deadline: 14 April 1997.
Exhibition contact: Harry Kuemmerle III, VIP Meetings & Conferences. Tel: +1 310 459 4691.
Contact: Mike Melloch, Purdue University, tel/fax: +1 317 494-3528/6441. Email: melloch@ecn.purdue.edu URL: <http://luciano.stanford.edu/ISCS/>

DRIP VII

The 7th International Conference on Defect Recognition & Image Processing will be held at Templin, near Berlin, Germany, on 7-10 September 1997.
Contact: J. Donocker, Institut für Kristallzüchtung im Forschungsverbund Berlin, Rudower Chausse 6, D-12489, Berlin. Tel/fax: +49 30 6392 2642/3003.

ICCBE-VI

6th International Conference on Chemical Beam Epitaxy and Related Growth Techniques will be held in Montreux, Switzerland, on 8-10 September 1997. The scope of this conference covers the entire spectrum of chemical beam epitaxy, gas source molecular beam epitaxy, and related growth technologies.
Abstract deadline is 1 April 1997.
Contact: Marc Illegems, Conference Chairman, Swiss Federal Institute of Technology Lausanne, Institute for Micro- and Optoelectronics, CH 1015 Lausanne. Tel/Fax: +41 21 693 54 12/10. E-mail: ilegems@imo.dp.epfl.ch

HITEN '97

The Second European Conference on High Temperature Electronics will be held at the Holiday Inn Crowne Plaza, Manchester, England on 14-17 September 1997.

Contact: Dr Colin Johnston, HITEN Technical Consultant, AEA Technology plc, 552 Harwell, Didcot, Oxon OX11 0RA, UK. Tel/fax: +44 (0)1235 434612/435780. E-mail: colin.johnston@aeat.co.uk

NPE97

The 1997 Nanophysics and Electronics Conference will be held at the Institute of Industrial Science and Institute of Solid State Physics, in Roppongi, Tokyo, Japan, on 18-20 September 1997. Abstract deadline is 30 May 1997. Attendance is limited to 150.

Contact: Prof. T. Ando, Chairman of NPE97, Institute of Solid State Physics, University of Tokyo, 7-22-1, Roppongi, Minato-ku, Tokyo 106, Japan. Tel/fax: +81 3 3478 6811/3402 7326. E-mail: ando@issp.u-tokyo.ac.jp

EP2DS XII

The 12th International Conference on the Electronic Properties of Two-Dimensional Systems will be held on 22-26 September in Tokyo, Japan, abstract deadline is 16 May 1997.

Contact: Prof. S. Komiyama, E-mail: csusumu@komaba.ecc.u-tokyo.ac.jp

Advanced Electron Microscopy and Analysis

An five-day intensive short course dealing with advanced electron microscopy and analysis will take place at the University of Surrey, Guildford, UK on 22-26 September 1997.

Contact: Derek Saunders, Dept of Materials Science and Engineering, University of Surrey, Guildford, GU2 5XH, UK. Tel/fax: +44 (0)1483 259612/259508; e-mail: D.Saunders@surrey.ac.uk

ACCGE/east-97

The Eastern Regional Conference on Crystal Growth & Epitaxy will be held at the Bally's Park Place Hotel & Casino, Atlantic City, NJ, USA, on 28 September-1 October 1997.

Abstract deadline is 30 April 1997

Contact: E. Wayne O'Dell, Program Chair, 28 Hillview Avenue, Morris Plains, NJ 07950-2115, USA. Tel/fax: +1 201 267 8277/455 3008. E-mail: ewodell@worldnet.att.net

NAMBE-XVI

The 16th N. American Conference on MBE will be held on 5-8 October at the University of Michigan, Ann Arbor, US.

Contact: PK Bhattacharya, tel/fax: +1 313 763 6678/9324. E-mail: pkb@eecs.umich.edu

GaAs IC Symposium

The 1997 IEEE GaAs IC Symposium will be at the Anaheim Marriott, Anaheim, CA, USA on 12-15 October. Coverage will embrace all aspects of the technology, from materials issues and device fabrication through IC design and testing, high volume manufacturing and systems applications.

Abstract deadline is 2 May 1997.

Contact: William Stanchina, Hughes Research Laboratories, tel/fax: +1 310 317-5089/5483. E-mail: wstanchina@msmail4.hac.com URL: <http://www.eecs.umich.edu/VLSI/GAASIC/>

ISS 97

The Tenth International Symposium on Superconductivity will be held in Gifu, Japan on 27-30 October 1997.

Contact: ISTE, Eishin Kaihatsu Bldg. 6F, 34-3 Shimbashi 5-chome, Minato-ku, Tokyo 105, Japan. Tel/fax: +81 3 3431 4002/4044.

ICNS97

The International Conference on Nitride Semiconductors will be held at the Tokushima Prefectural Culture Hall in Tokushima, Japan, on 27-31 October 1997.

Contact: Dr S. Yoshida, Steering Chair, ICNS97, Materials Science Div., Electrotechnical Lab, 1-1-4 Umezono, Tsukuba, Ibaraki 305, Japan. Tel/fax: +81 298 54-5222/58-5434. E-mail: syoshida@etl.go.jp; URL: <http://www-icns.ee.tokushima-u.ac.jp>

5NACC

The Fifth North American Chemical Congress on Dynamics and Chemistry of Thin Film Growth will take place in Cancun, Mexico on 11-15 November 1997.

Contact: Martin Zinke-Allmang, Centre for Chemical Physics, University of Western Ontario, London, Ontario, Canada N6A 3K7. Tel/fax: +1 519 661-3986/-3032; e-mail: mzinke@uwo.ca

Scanning Probe Microscopy

An five-day intensive short course dealing with scanning probe microscopy will take place at the University of Surrey, Guildford, UK on 17-21 September 1997.

Contact: Derek Saunders, Dept of Materials Science and Engineering, University of Surrey, Guildford, GU2 5XH, UK. Tel/fax: +44 (0)1483 259612/259508; e-mail: D.Saunders@surrey.ac.uk

MRS Fall '97

The MRS Fall Meeting will take place in Boston, MA, USA on 1-5 December 1997.

Contact: MRS, tel/fax: +1 412 367-3003/4373; E-mail: info@mrs.org; URL: <http://www.mrs.org/>

IEDM 1997

The 1997 IEEE International Electron Devices Meeting will take place in Washington, DC, USA on 7-10 December 1997.

Abstract deadline is 30 June 1997.

Contact: Phyllis Mahoney, IEDM, 101 Lakeforest Boulevard, Suite 270, Gaithersburg, MD 20877, USA. Tel/fax: +1 301 527-0900/-0994; e-mail: pwmahoney@aol.com; URL: www.ieee.org/conference/iedm

HiTEC '98

The Fourth International High Temperature Electronics Conference will be held at Albuquerque, NM, USA on the 14-19 June 1998.

Abstract deadline is 1 July 1997.

Contact: Debbie Marchand, Tech Reps. Inc., 5000 Marble NE, Suite 222, Albuquerque, NM 87110-6390, USA. Tel/fax: +1 505